

GPR2823

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Applicant: Goldberg, et al.

Art Unit: 2823

Serial No.: 09/085,298

Examiner: Eaton, K.

Filing Date: 5/27/98

Docket No.: TI-25588

Title: METHOD FOR THERMAL NITRIDATION AND/OR OXIDATION
OF SEMICONDUCTOR SURFACE AND RELATED PROCESSING
EQUIPMENT

H/B
JCM
2-24-00

Amendment under 37 CFR 1.115

Assistant Commissioner of Patents
Washington, DC 20231
February 16, 2000

Dear Sir:

MAILING CERTIFICATE UNDER 37 C.F.R. §1.8(A)
I hereby certify that this correspondence is being deposited with
the U.S. Postal Service as First Class Mail in an envelope addressed
to: Assistant Commissioner for Patents, Washington, D.C. 20231 on
2-17-00

Tommie Chambers
Tommie Chambers

The following amendments and remarks are offered in response to the Examiner's Office Action dated 11/17/99. They are respectfully submitted as a full and complete response to that Action.

Please amend the above-referenced application as follows:

In the Claims:

Please amend the claims as follows:

4. (amended) The method of claim 1, wherein said silicon-containing structure is a silicon substrate and said nitrided portion of said silicon-containing structure is a gate dielectric.